



PATENT
Attorney Docket No. 03180.0350

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
)
Hiroko NAKAMURA et al.)
)
Application No.: 10/760,522)
) Group Art Unit: 2123
Filed: January 21, 2004)
) Examiner: Dwain M. Craig
For: A METHOD FOR A PREDICTING A)
PATTERN SHAPE BY USING AN)
ACTUAL MEASURED)
DISSOLUTION RATE OF A) Confirmation No.: 1093
PHOTOSENSITIVE RESIST (As)
amended))

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

AMENDMENT

In reply to the Office Action mailed December 20, 2006, the period for response having been extended to May 21, 2007 (May 20, 2007, being a Sunday) by a Petition for Extension of Time of two months and fee payment to be drawn from Deposit Account 06-0916, please amend the above-identified application as follows:

Amendments to the Specification are included in this paper.

Amendments to the Claims are reflected in the listing of claims in this paper.

Remarks follow the amendment sections of this paper.

Attachments to this paper include a copy of a PTO Form 1449 included with an Information Disclosure Statement (IDS) submitted August 12, 2004.

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02 FC:1201 200.00 DA
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